

## Table of Contents

|                                                                                                                                                              |     |
|--------------------------------------------------------------------------------------------------------------------------------------------------------------|-----|
| <b>Diffusion in Silicon and Germanium</b>                                                                                                                    | 1   |
| <b>Semiconductors</b>                                                                                                                                        | 103 |
| <b>Halides, Oxides, Simple Oxides, Spinel, Garnets, other Complex Oxides, other Ionic Substances, Niobates, Nitrates, Phosphates, Silicates and Sulfates</b> | 141 |
| <b>Carbon and Carbides, Hydrides, Nitrides, Sulfides and Selenides, Organic Compounds, Miscellaneous and Metals</b>                                          | 185 |
| <b>General References, Diffusion Processes, Point Defects, Linear Defects, Planar Defects, Irradiation Effects and Ionic Conduction</b>                      | 223 |
| <b>Author Index</b>                                                                                                                                          | 241 |
| <b>Materials Index</b>                                                                                                                                       | 296 |
| <b>Subjects Index</b>                                                                                                                                        | 333 |